

Supplementary Information

In situ engineering of NanoBud geometries

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Transmission Electron Microscopy

High resolution imaging was at 80kV was carried out using the Oxford JEOL JEM-2200MCO aberration-corrected, field-emission gun transmission electron microscope. A Gatan Ultrascan 4k x 4k CCD camera was used for image recording, at 1 second acquisition times.

Aberration correction was undertaken analysing a phase plate (figure S1 a) resolved from a tableau of diffractograms taken a varying incident beam tilts (figure S1 b). Table S1 shows resulting values of beam aberrations prior to recording images.

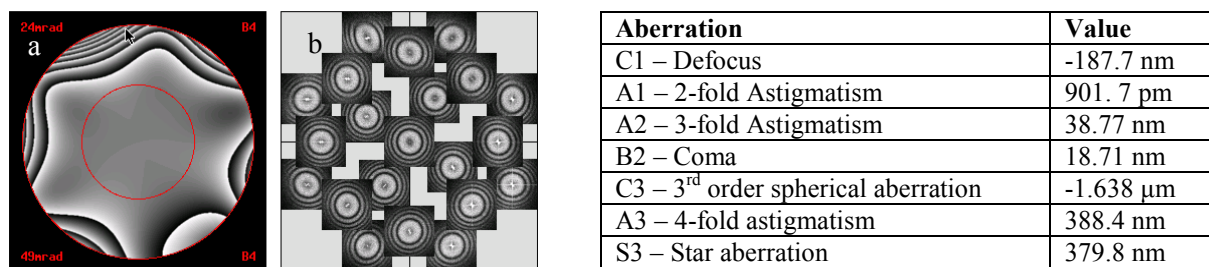


Figure S1: (a) Phase plate analysis of (b) 21 diffractograms in tableau. **Table S1:** Corresponding aberration values prior to image sequence.

NanoBud transformation was observed under beam irradiation, in real time at ambient temperature.